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IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :
RAVINDRANATH DROOPAD ET AL : EXAMINER: BAUMEISTER
SERIAL NO: 09/901,109 :
FILED: JULY 10, 2001 : GROUP ART UNIT: 2815
FOR: STRUCTURE AND METHOD FOR :
FABRICATING SEMICONDUCTOR :
STRUCTURES AND DEVICES :
UTILIZING THE FORMATION OF A :
COMPLIANT SUBSTRATE COMPRISING :
AN OXYGEN-DOPED COMPOUND :
SEMICONDUCTOR LAYER :

AMENDMENT

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

Responsive to the Official Action dated June 20, 2003, Applicants respectfully request reconsideration in view of the following amendment and remarks.

The Claims begin on page 2 of this paper.

Remarks/Arguments begin on page 3 of this paper.

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